
 INFORMATION DISCLOSURE CITATION (Use several sheets if necessary) MAR 14 2005				ATTY DOCKET NO.		APPLICATION NO.		
				BUR920040033US1		10/711.818		
				APPLICANT(S) William J. Murphy et al.				
FILING DATE				GROUP ART UNIT				
10/07/2004				1753				
U.S. PATENT DOCUMENTS								
*EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
U.S. PATENT APPLICATION PUBLICATIONS								
*EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
FOREIGN PATENT DOCUMENTS								
		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO
/RM/		JP3287764	12/1991	Japan				
/RM/		JP9041135	02/1997	Japan				
/RM/		JP04032567	02/1992	Japan				
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)								
/RM/		SIMPLICITY IN SPUTTERING, US Inc., Planar Magnetron Sputtering Source, 7 pages.						
/RM/		MAGNETRON SPUTTERING, Plasma Surface Engineering Corporation, TN 0001000 02/03, 4 pages.						
EXAMINER				DATE CONSIDERED				
/Rodney McDonald/				03/26/2008				
*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.								

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				William J. Murphy et al. FILING 10/07/2004 GROUP ART 1753				
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							YES	NO
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)								
/RM/		J. R. German, A SIMPLE LOW COST METHOD FOR INCREASED PERFORMANCE OF PLANAR MAGNETRON SPUTTERING TARGETS, pages 1-5.						
EXAMINER /Rodney McDonald/				DATE CONSIDERED 03/26/2008				

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